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Technical Compliance

No. ACS-E20160

The following product has been tested by us with the listed standards and found in compliance with the council EMC directive 2014/30/EU It is demonstrative for the compliance with this EMC Directive.

Applicant : Shenzhen Century Cloud Core Technologies Limited
 F1-F5, B1 Complex Building, Gangtuo Industrial Park, Yabian
 Community, Shajing Town, Baoan District, Shenzhen

Product : SERVER

Model No. : 240-Zz

Test Standards :

| | | |
|---|---|---------------------------------------|
| EN 55032: 2012+AC: 2013 (Class A) EN 55032: 2015 | Electromagnetic compatibility of multimedia equipment - Emission requirements | |
| EN 61000-3-2: 2014 | Electromagnetic compatibility(EMC) Part 3-2:Limits-Limits for harmonic current emissions(equipment input current \leq 16A per phase) | |
| EN 61000-3-3: 2013 | Electromagnetic compatibility(EMC) Part 3-3:Limits-Limitation of voltage changes, voltage fluctuations and flicker in public low-voltage supply systems, for equipment with rated current \leq 16A per phase and not subject to conditional connection | |
| EN 55035: 2017 | Electromagnetic compatibility of multimedia equipment — Immunity requirements | |
| | IEC 61000-4-2: 2008 | Electrostatic Discharge |
| | IEC 61000-4-3: 2010 | RF Field Strength Susceptibility |
| | IEC 61000-4-4: 2012 | Electrical Fast Transients |
| | IEC 61000-4-5: 2014 | Surge |
| | IEC 61000-4-6: 2013 | Continuous Conducted disturbance |
| | IEC 61000-4-8: 2009 | Magnetic Field Immunity |
| | IEC 61000-4-11: 2004 | Dips / Voltage Interruption Variation |



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 Audix Technology (Shenzhen) Co., Ltd.
 EMC 部門報告專用章

Stamp only for EMC Dept. Report

Signature:

Bensun Chen
 Manager

Date : Jul.15, 2020

The technical compliance is based on a single evaluation of one sample of above mentioned product. It does not imply an assessment of the whole production and does not permit the use of the test lab. logo.